

Electronic Supplementary Information

Fabrication of Bi₁₉S₂₇I₃ nanorod cluster film for enhanced photodetection performance

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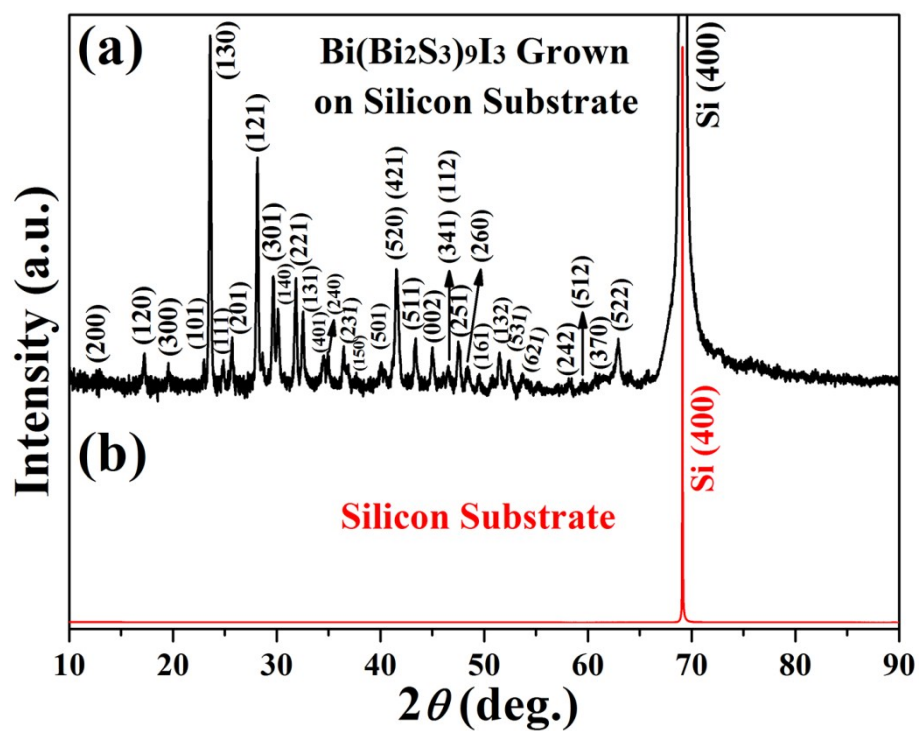


Fig. S1 XRD patterns of (a) the prepared $\text{Bi}_{19}\text{S}_{27}\text{I}_3$ thin film on silicon wafer and (b) the corresponding bare substrate.

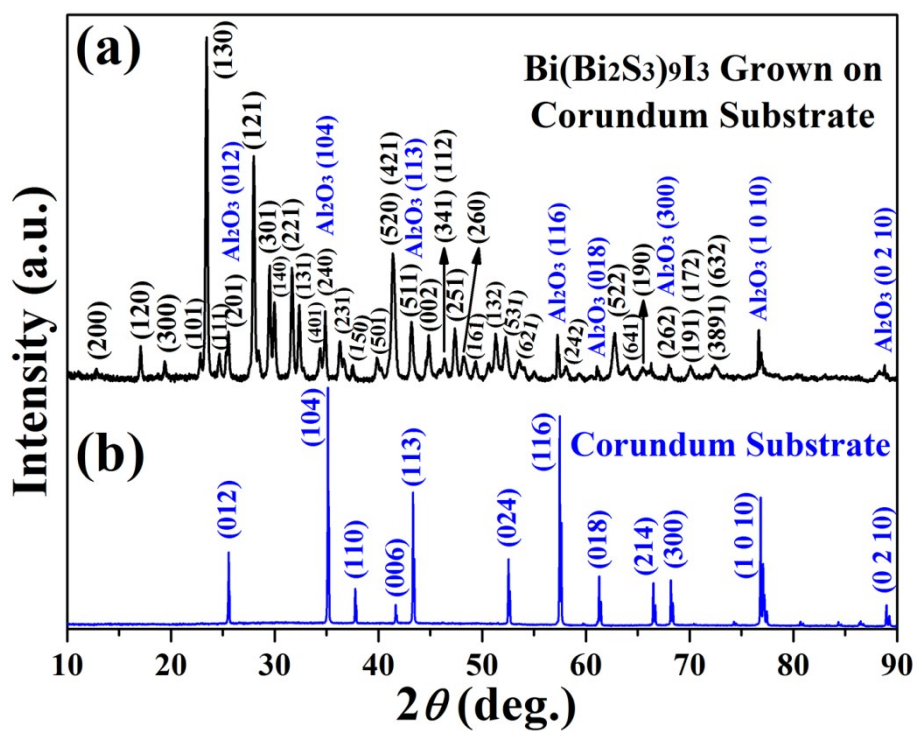


Fig. S2 XRD patterns of (a) the prepared Bi₁₉S₂₇I₃ thin film on corundum wafer and (b) the corresponding bare substrate.

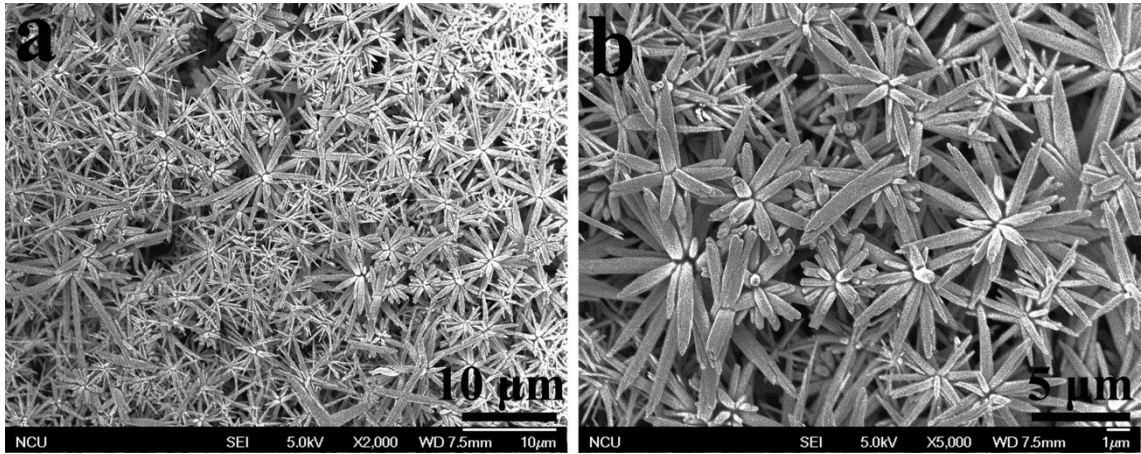


Fig. S3 (a) Low-magnification and (b) high-magnification SEM images of the prepared $\text{Bi}_{19}\text{S}_{27}\text{I}_3$ thin film on silicon wafer.

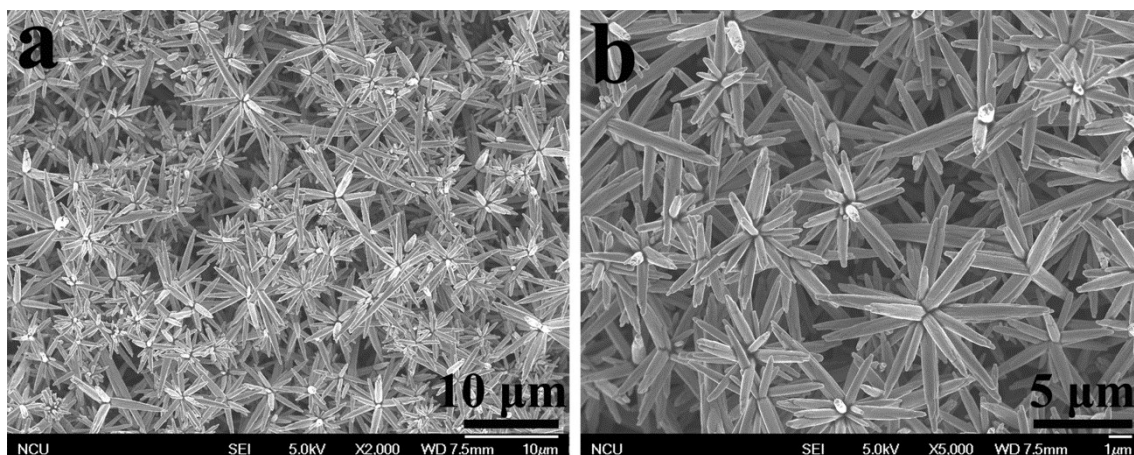


Fig. S4 (a) Low-magnification and (b) high-magnification SEM images of the prepared $\text{Bi}_{19}\text{S}_{27}\text{I}_3$ thin film on corundum wafer.